Study of the Structural and Electronic Properties of Neutral and Charged Niobium-Doped Silicon Clusters: Niobium Encapsulated in Silicon Cages

Xin Xin Xia,†,§ Andreas Hermann,§ Xiao Yu Kuang,*† Yuan Yuan Jin,† Cheng Lu,*‡† and Xiao Dong Xing‡

†Institute of Atomic and Molecular Physics, Sichuan University, Chengdu 610065, China
‡Department of Physics, Nanyang Normal University, Nanyang 473061, China
§Centre for Science at Extreme Conditions and SUPA, School of Physics and Astronomy, The University of Edinburgh, Edinburgh EH9 3JZ, United Kingdom
¶Beijing Computational Science Research Center, Beijing 10084, China

ABSTRACT: We performed systematic structure searches for low energy structures of neutral and singly charged niobium-doped silicon clusters NbSiQ (n = 2−20; Q = 0, ±1) by means of the CALYPSO structure searching method. A large population of low energy clusters is collected from the unbiased structure search. Subsequent geometry optimizations using density-functional theory with the B3LYP exchange-correlation functional are carried out to determine structural patterns and relative stabilities of various low energy candidates for Nb-doped silicon clusters. Based on the calculated binding energies along with measured photoelectron spectroscopy data, we are able to confirm that our lowest energy structures are the true minima. It is shown that the localized position of the Nb impurity atom in NbSiQ clusters gradually moves from the convex capping position, to surface-substituted, to the concave, and in the end to the encapsulated state as the number of Si atoms increases from 2 to 20. The lowest energy isomer of both neutral and anionic NbSi12 cluster is very stable in a high-symmetry endohedral D4h structure in which the Nb atom is placed at the center of a regular hexagonal prism of Si atoms. This makes it an attractive building block for cluster-assembled materials.

1. INTRODUCTION

Emissions of carbon oxides, particularly carbon dioxide (CO2), have aroused global attention and have evolved into a pressing environmental challenge to humanity in recent decades. The most effective way to reduce CO2 emissions is to increase the operational efficiency and decrease the emission of undesired gases in conventional power plants. Improvements in heat efficiency can usually be realized by increasing the temperature at which the turbines operate. With this in mind, the development of new refractory materials, more advanced than the conventional materials used in turbines, is crucial. Transition-metal silicides, such as niobium silicide, are attractive candidates for structural applications at ultrahigh temperatures above 1350 °C due to their high melting points, superior strength to density ratio, and excellent oxidation resistance at high temperatures. In the past few years, extensive work has been performed on niobium silicides. Studies concentrate on the formation of amorphous niobium silicide and have suggested that nanoclusters play a role in such chemical processes. It is therefore very important to explore the evolution of patterns in the microstructure and the electronic properties of niobium silicide aggregates in the transition from the molecular to the condensed phase.

There have been a number of gas-phase experimental studies on the structural and electronic properties of the NbSi nanoalloy clusters. Cations/neutrals/anions of silicon clusters doped with one metal atom (M = Sc, Y, Lu, Ti, Zr, Hf, V, Nb, and Ta) were generated by the double-laser vaporization method in a modified cluster source, and their stability was characterized with mass spectroscopy, adsorption reactivity, and photoelectron spectroscopy (PES). Combined anion photoelectron spectroscopy and computational studies on the transition metal—silicon diatomic species (NbSi, MoSi, PdSi, and WSi) showed that the composition of the highest occupied molecular orbitals shift from a majority of transition-metal s- and d-orbital contributions in ZrSi and NbSi to mainly silicon p-orbital contributions for MoSi and PdSi. Despite the enormous progress that has been made, relatively little is known about the evolution of structural and electronic properties on Nb-doped silicon clusters, and theoretical studies on medium-size-range clusters are currently lacking. The main reason may be because the computational methods used for small clusters are not practical for medium-sized clusters.
Moreover, the determination of the true global minimum structure of a given cluster size is a challenging problem because of the much increased complexity of the potential surface and the exponential increase of the number of low energy structures with cluster size.

In order to verify existing experimental results and to examine the relative stability of the metal Nb atom encapsulated inside Si clusters, we have carried out extensive structure searches of neutral and charged Nb-doped silicon clusters in the size range from 2 to 20 using the CALYPSO (Crystal structure AnaLYsis by Particle Swarm Optimization) package. The following interesting results have emerged: (i) When the transition-metal Nb is doped into silicon clusters, the position of the Nb impurity atom gradually moves, with increasing cluster size, from a convex capping site to a surface substitute site, then to a concave, and in the end to an encapsulated site. (ii) While Nb occupies an endohedral position in most neutral and anionic clusters, the structure of NbSi$_{12}$ is highly symmetric, with Nb centered in a Si$_{12}$ hexagonal prism. (iii) The structural properties of Nb-doped silicon clusters are different from those of pure silicon clusters, implying that doping the transition metal Nb atom into pure silicon clusters has significant effects on their stability and electronic properties. The paper is organized as follows. In section 2, we describe the details of the computational method, while in section 3 we present our results and discussion. Finally, we summarize our main conclusions in section 4.

2. COMPUTATIONAL DETAILS

We used the CALYPSO method to search for the geometries of low-lying isomers of neutral and charged Nb-doped silicon clusters. A local version of the particle swarm optimization (PSO) algorithm is implemented to utilize efficient global minimization of free-energy surfaces for a given nonperiodic system. The algorithm can identify stable structures based on only the chemical composition. It has made a variety of successful predictions for structures of, for example, nanoparticles, layered materials, crystals, clusters, and so on. Details of the theoretical methodology have been published elsewhere. Here, structure predictions of neutral and charged Nb-doped silicon clusters up to 20 silicon atoms are carried out. In the particle swarm optimization method, cluster structures are ordered by generations. Each generation contains 50 structures, 60% of which are generated by the particle swarm optimization algorithm, while the others are generated randomly. We have followed 30 generations to achieve convergence around the lowest minima of the potential energy surface. The searches generated a large database for low energy neutral, anionic and cationic Nb-doped silicon clusters. Low energy structures within 4 eV of the global minimum structure were reoptimized with subsequent frequency calculations. The calculations are performed within the spin unrestricted density functional theory method with the hybrid B3LYP exchange-correlation functional. The LANL2DZ basis set for the transition-metal Nb atom and the 6-311+G(d) basis set for Si atom were used. The effect of the spin multiplicity was considered (up to septet and octet) and no symmetry constraints are enforced during the geometry optimization. For each isomer, harmonic vibrational frequencies are calculated to make sure that the structures correspond to real local minima without imaginary frequency. All calculations are performed using the Gaussian 09 program package.
photoreaction spectra are simulated using the time-dependent-DFT (TD-DFT) method, which provides a first-principal
method for the calculation of excitation energies and can be
used to calculate the positions of the PES peaks exactly. This
approach has applied successfully in recent years to studies of
organic molecules and small clusters.\textsuperscript{33–37} Chemical-bonding
analysis is performed using the adaptive natural density
partitioning (AdNDP)\textsuperscript{36} method.

The accuracy of the B3LYP functional has been found to be
questionable for bulk solids, involving metal atoms.\textsuperscript{39–41} Paier
et al.\textsuperscript{42},\textsuperscript{43} concluded that B3LYP gives much larger errors than
PBE\textsuperscript{0},\textsuperscript{42},\textsuperscript{43} in particular, for transition metals, on lattice
constants, bulk modulus, and atomization energies. We have
therefore reoptimized all of the low-lying isomers with the
PBE\textsuperscript{0} functional and performed frequency calculations as well.
The choice of PBE\textsuperscript{0} functional is based on some previous
reports.\textsuperscript{39,44,45} The structural and energy trends obtained using
the PBE\textsuperscript{0} functional are found to be the same as obtained using
the B3LYP functional, with a slight increase in the total energy
values in case of the PBE\textsuperscript{0} functional as compared to the
B3LYP functional. The relative energy trends obtained with the
PBE\textsuperscript{0} functional are listed in Table S1 (in the Supporting
Information, SI). Compared with the experimental PES of Nb-
doped silicon clusters (discussed below), we can also see that
the results from the B3LYP level (Figure 1) are better than
those from the PBE\textsuperscript{0} functional (Figure S1) for NbSi\textsubscript{5}\textsuperscript{−} clusters.
In fact, B3LYP is the most popular “hybrid” functional in the
quantum chemistry community and will allow for reliable
comparisons of these results.\textsuperscript{46–48} We believe that the B3LYP
exchange-correlation functional can give reliable structures and
energies for Nb-doped silicon clusters, and here we base our
discussion on B3LYP results.

3. RESULTS AND DISCUSSION

3.1. Geometric Structure. We have performed unbiased
searches for the global minima structures of neutral, anionic,
and cationic Nb-doped silicon clusters in the size range $2 \leq Q
\leq 20$. A large number of isomers, about $1000–1500$ isomers,
are obtained for each cluster size and optimized during the
structure searches. Here, we concentrate on the lowest energy
structures and some important structural isomers for the
neutral, anionic, and cationic species. The lowest energy
structures of neutral, anionic, and cationic NbSi\textsubscript{Q}\textsuperscript{\textminus} ($n = 2–20$; $Q
= 0, \pm 1$) clusters are displayed in Figure 2. All structures are
confirmed to be energetic minima from analysis of their
vibrational frequencies. Most of the optimized structures are
found to prefer a low spin state, i.e., the singlet state for closed-
shell and the doublet state for open-shell clusters. The
electronic states and point group symmetry of all these lowest
energy structures are summarized in Table 1. The harmonic
vibrational frequencies are listed in Tables S2–S4 (SI). Other
typical low-lying isomers of NbSi\textsubscript{Q}\textsuperscript{\textminus} ($n = 2–20$; $Q
= 0, \pm 1$) clusters together with their point groups and relative energies
are shown in Figures S2–S4 in the SI.

For both neutral and charged species, only the smallest
cluster ($n = 2$) forms planar structures. For $n \geq 3$, it is evident
that the equilibrium structures are three-dimensional config-
urations. In the lowest energy structure of both neutral and
charged NbSi\textsubscript{3} clusters, three Si atoms form a regular triangle
and the Nb atom joins at the apex to form a trigonal pyramid.
The lowest energy geometries of NbSi\textsubscript{Q}\textsuperscript{\textminus} ($Q = 0, \pm 1$) are
slightly distorted trigonal bipyramids. The four Si atoms form
a folding plane of the trigonal bipyramid, which is capped by the

Figure 2. Lowest energy structures of NbSi\textsubscript{Q}\textsuperscript{\textminus} ($n = 2–20$; $Q
= 0, \pm 1$) clusters. The red (yellow) spheres represent the Nb (Si) atoms.

Nb atom. As for the most stable structure of NbSi\textsubscript{Q}\textsuperscript{\textminus} ($Q = 0,
\pm 1$) clusters, both $C_{3v}$ symmetry NbSi\textsubscript{4} and $C_{4v}$ symmetry NbSi\textsubscript{5−}
can be viewed as a boat-shaped structure with the doped Nb
atoms at different positions. The $C_{4v}$ symmetry NbSi\textsubscript{5−} cluster
can be viewed as a Si atom capping the bottom of a distorted
NbSi\textsubscript{5−} cluster, forming a square bipyramidal. As the number of
Si atoms increases, the preferred position of the Nb atom
gradually moves from convex capped sites to encapsulated sites.
In the NbSi\textsubscript{10}\textsubscript{3+} ($Q = 0, \pm 1$) clusters, the Nb atom tends to
move inside a caged silicon framework (except for NbSi\textsubscript{10}+, where
the Nb atom still localizes at the surface site of the silicon
frame). We find that the Nb atom is fully encapsulated by the
silicon framework for $n \geq 12$. From $n = 12$ through $n = 20$, the
lowest energy structures of NbSi\textsubscript{Q}\textsuperscript{\textminus} ($Q = 0, \pm 1$) are distorted Si
cages surrounding the Nb impurity. In addition, except for
NbSi\textsubscript{17−} and NbSi\textsubscript{19−}, the lowest energy structures of NbSi\textsubscript{Q}\textsuperscript{\textminus} ($n
= 17–20$; $Q = 0, \pm 1$) clusters can be seen as double cage
structures, where the Nb atom is encapsulated by two
connected silicon units. It should be mentioned that the lowest
energy isomers of neutral and anionic NbSi\textsubscript{Q}\textsuperscript{\textminus} ($Q = 0, -1$)
can be found very quickly, typically within 10
 generations. For cationic NbSi\textsubscript{5−}, however, the lowest energy
structure was much harder to obtain, largely because there are
two competing lowest-energy isomers with very different
structures. More interestingly, and in contrast to cationic
The VDE of NbSi indeed the ground-state structures of NbSi energy isomers are shown in displayed in ground state structures combine with the experimental PES are 3.80 eV, which successfully reproduces the experimental results. The simulated PES of NbSi contains four peaks (X, A, and B) at 3.38, 3.44, 3.46, and 3.51 eV, which are 0.15, 0.21, 0.26, and 0.32 eV lower, respectively, than the experimental peaks. The simulated PES of NbSi yields four obvious peaks (A–D) seen in the simulated PES are in general agreement with the experimental spectrum, while the first peak (X) is at unexpectedly low energy, at 3.02 eV. Similar situations occur for both NbSi and NbSi, namely, there is an excess peak (X) obtained in the simulated PES. The simulated spectrum of NbSi yields two obvious peaks (X and A) at 4.26 and 5.00 eV, in very good agreement with the experimental results. The simulated PES of NbSi exhibits a small broadened feature, and the first small peak appears at 4.05 eV, which is very close to the experimental result. For NbSi, the simulated spectrum agrees excellently with experiment and contains four peaks (X, A–C). In the simulated spectrum of NbSi, three peaks are observed as in the experimental PES, although the overall spectrum is slightly broader and moved to lower energy compared to experiment. A similar situation occurs for NbSi. For NbSi, the experimental spectrum is successfully reproduced by the simulated spectrum, both of them shows the same trend and yield three peaks (X, A, and B). In the PES of NbSi, three peaks (X, A, and B) increase in height, can be seen in both experimental and theoretical results. The simulated spectrum of NbSi shows four almost evenly spaced obvious peaks (A–D) and one weak peak (X), in which the VDE is about 3.23 eV. For NbSi, the simulated spectrum yields three peaks (X, A and B) at 3.38, 4.40, and 5.25 eV, respectively. As stated above, we find that the simulated PES spectra of anionic NbSi (n = 2–20) clusters are mostly in very good agreement with experiments, confirming that the ground-state structures we obtained are true global minima.

### 3.2. Photoelectron Spectra of Anionic NbSi Clusters.

To probe whether the geometries, as shown in Figure 2, are indeed the ground-state structures of NbSi (n = 2–20; Q = 0, ± 1) clusters, the photoelectron spectra of anionic NbSi (n = 2–20) clusters are simulated using TD-DFT and compared to the available experimental results. The simulated spectra of ground state structures combine with the experimental PES are displayed in Figure 1. The simulated spectra of other low energy isomers are shown in Figure S1. Each peak of the PES represents a transition from the ground state of the cluster anion to the ground or an excited state of their corresponding neutrals. The simulated spectrum of NbSi shows three major peaks (X, A, and B) and the first peak (X) is located around 1.65 eV, which gives the vertical detachment energy (VDE). The VDE of NbSi is about 2.33 eV. After the first peak, there are two peaks between 3 and 4 eV. The first three peaks (X, A, and B) of the PES of NbSi are similar to those of NbSi and the VDE is about 2.40 eV. For NbSi, there are four major peaks and the first peak (X) is very small, corresponding to a VDE of 2.74 eV. The simulated spectrum of NbSi exhibits a weak peak (X) centered at 2.58 eV and an intense peak (A) at 3.80 eV, which successfully reproduces the experimental features. The calculated VDE is also in good agreement with the experimental result of 2.75 eV. For NbSi, four discrete peaks (X, A–C) are found at 3.15, 3.90, 4.45, and 5.15 eV in the simulated spectrum. A similar four-peak structure is also seen in the experimental PES and the VDE is in agreement with experimental value 3.29 eV. For the PES of NbSi, both theoretical and experimental measurements yield four peaks (X, A–C) and have similar VDE value. For NbSi, the four obvious peaks (A–D) are observed in the simulated PES and are in general agreement with the experimental spectrum, with the first peak (X) at unexpectedly low energy, at 3.02 eV. Similar situations occur for both NbSi and NbSi, namely, there is an excess peak (X) obtained in the simulated PES. The simulated spectrum of NbSi yields two obvious peaks (X and A) at 4.26 and 5.00 eV, in very good agreement with the experimental results. The simulated PES of NbSi exhibits a small broadened feature, and the first small peak appears at 4.05 eV, which is very close to the experimental result. For NbSi, the simulated spectrum agrees excellently with experiment and contains four peaks (X, A–C). In the simulated spectrum of NbSi, three peaks are observed as in the experimental PES, although the overall spectrum is slightly broader and moved to lower energy compared to experiment. A similar situation occurs for NbSi. For NbSi, the experimental spectrum is successfully reproduced by the simulated spectrum, both of them show the same trend and yield three peaks (X, A, and B). In the PES of NbSi, three peaks (X, A, and B) increase in height, can be seen in both experimental and theoretical results. The simulated spectrum of NbSi shows four almost evenly spaced obvious peaks (A–D) and one weak peak (X), in which the VDE is about 3.23 eV. For NbSi, the simulated spectrum yields three peaks (X, A and B) at 3.38, 4.40, and 5.25 eV, respectively. As stated above, we find that the simulated PES spectra of anionic NbSi (n = 2–20) clusters are mostly in very good agreement with experiments, confirming that the ground-state structures we obtained are true global minima.

### 3.3. Ionization Potential, Electron Affinity, and Charge Transfer.

The calculated adiabatic ionization potential (AIP), vertical ionization potential (VIP), vertical electronic affinity (VEA), adiabatic electronic affinity (AEA), and VDE of niobium-doped silicon clusters are summarized in Table 2, together with the available experimental data for comparison. The ionization potential and electron affinity potential as functions of cluster size are shown in Figure 3. From Figure 3a,
Comparison (All Energies in eV)

Clusters together with the available experimental data for 0.00, 0.03, and 0.07 eV, indicating that the anionic NbSi and neutral and anionic clusters. It should be noted that the diversity between the lowest energy structure of VEA show similar oscillations in the region of the corresponding neutral state.

Cluster basically keeps the structural framework of the NbSi except for (Figure 3).

Reference 50.

The charge on Nb atom for the lowest energy NbSi\(_n^Q\) (n = 2–20; Q = 0, ±1) clusters by natural population analysis (NPA) is shown in Table 1. Except for NbSi\(_6^Q\) and NbSi\(_8^Q\), it is found that the charge on Nb atom is negative for all the neutral species, which means that, in most of the cases, the Si atoms act as a donor and the Nb atom is an acceptor. For cluster size of n = 5–20, the transfer negative charges increase significantly and reaches a maximum value of ~4.36e at n = 15. In the case of anions, the extra electron is located on both the Nb atom and the Si framework with n = 2–6 because the charge on Nb atom is smaller than 1 (−e). For the anions with n ≥ 7, the charge on Nb atom is larger than the extra electron. In other words, there is electron transfer from the Si framework to the Nb atom. The largest charge on Nb atom is ~3.72e occurred on NbSi\(_{15}^-\). The charges on the Nb atom of cationic clusters show that the extra positive charge is mainly donated from Si framework. The natural electron configuration (NEC) for the lowest energy NbSi\(_n^Q\) (n = 2–20; Q = 0, ±1) clusters are listed in Tables S5–S7 (SI). Quite clearly, the charges transfer from Si atoms to the Nb atom, which is consistent to the above NPA analysis. Except for a few structures like NbSi\(_{14}^Q\), the deviation of natural charges on Nb atoms in NbSi\(_n^Q\) (n = 2–20; Q = 0, ±1) is less than 1e during the structure transformation of forming a cagelike structure, especially for the anionic clusters.

3.4. Relative Stabilities and HOMO–LUMO Gaps. The average binding energy (E\(_b\)) of a cluster is a useful measure of its inherent stability and is defined as follows

\[
E_b = \frac{nE(Si) + E(NbSi^Q) - E(NbSi_{n}^Q)}{n + 1}\]

where E is the total energy of the corresponding cluster or atom. The E\(_b\) of ground state NbSi\(_n^Q\) (n = 2–20; Q = 0, ±1) clusters as a function of the number n of Si atoms are plotted in Figure 4a. Larger E\(_b\) values indicate higher stability. Except for NbSi\(_1^Q\) and NbSi\(_3^Q\), all of the neutral NbSi\(_n^Q\) have lower E\(_b\) values than their cationic and anionic states, suggesting that it is generally energetically favorable for the neutral NbSi\(_n^Q\) species either to donate or receive charge. It is also easily seen that for all three charge states of the clusters, the binding energies gradually increase with growing cluster size and feature a distinct maximum at n = 16, signifying that NbSi\(_{16}^-\) are the most stable clusters in the range studied here. For larger clusters, n > 16, the binding energies decrease somewhat. For the neutral and anionic species, two additional local maxima of the binding energy are found n = 7 and 12, indicating that these cluster sizes are more stable than their adjacent sized clusters. For the cationic clusters, three slight local maxima of E\(_b\) show that NbSi\(_{6,8,9}^Q\) have relatively strong energetic stability.

The second-order difference of the energy (\(\Delta^2E\)) can reflect the relative stability of neutral and charged clusters compared to their smaller or larger neighbors. For NbSi\(_n^Q\) (n = 2–20; Q = 0, ±1) clusters, \(\Delta^2E\) can be defined as

\[
\Delta^2E = E(NbSi_{n-1}^Q) + E(NbSi_{n+1}^Q) - 2E(NbSi_n^Q),
\]

Q = 0, ±1

The \(\Delta^2E\) values for all NbSi\(_n^Q\) (n = 2–20; Q = 0, ±1) clusters are shown in Figure 4b. It shows similar odd–even oscillating behaviors in the range of n = 2–8 and n = 11–19 for neutrals and anions. Several distinct peaks are found at n = 3, 5, 6, 7, 12, 14, and 16, indicating that the clusters NbSi\(_{3}^Q\), NbSi\(_{5}^Q\), NbSi\(_{6}^Q\), NbSi\(_{8}^Q\), NbSi\(_{9}^Q\), and NbSi\(_{16}^Q\) are more stable.
than their neighbors. This result is in accordance with the findings from the average binding energy. For cationic NbSi₆⁻ clusters, an irregular oscillating behavior occurs in the range of \( n < 13 \), and an odd—even oscillation, which is similar to the neutral species, is also found for the cations with \( n = 13–18 \).

The HOMO–LUMO energy gap (\( E_{\text{gap}} \)) is a useful quantity to represent the ability of an electron to jump from occupied orbitals to unoccupied orbitals. Larger values of \( E_{\text{gap}} \) suggest neutral clusters are less stable, which is in excellent agreement with the results of averaged binding energies shown in Figure 4a. As for anionic NbSi₁₆⁻ clusters, three local maxima for \( E_{\text{gap}} \) values of 2.76 eV, 2.70, and 1.90 eV are found at \( n = 11, 12, \) and 16, respectively, suggesting that NbSi₁₁₋₁₆⁻ are more stable than other clusters. The local maxima of the \( E_{\text{gap}} \) for neutral and cationic clusters suggest that neutral NbSi₁₆,₆,₉,₁₁,₁₁,₁₆⁻ possess enhanced relative stability. Combining the above analysis on \( \epsilon_{\text{p}} \), \( \Delta E \), and \( E_{\text{gap}} \) values of NbSi₁₆⁻ (\( n = 2–20; Q = 0, \pm 1 \)) clusters, the cationic NbSi₁₆⁺ as well as anionic NbSi₁₂₋₁₆⁻ can be viewed as “magic” clusters with enhanced stability.

### 3.5. Chemical-Bonding Analysis

For an in-depth understanding of the niobium-doped silicon clusters, we analyzed their molecular orbitals (MOs). For simplicity, we present here only the molecular orbitals along with the energy levels of the NbSi₁₂⁻ cluster, which features one of the largest HOMO–LUMO energy gaps, 2.70 eV, across all clusters studied (see Figure 5). The LUMO, corresponding to Si–Si π bonds, is formed primarily by s- and p-orbitals of peripheral Si atoms. For the occupied MOs HOMO, HOMO-5, HOMO-6, and HOMO-7, the combination of p-orbitals in the peripheral Si atoms results predominately in the formation of delocalized π bonds. The HOMO-1 features σ bonds between the p-orbitals of the peripheral Si atoms and the d-orbital of the central Nb atom, and the MOs HOMO-2, HOMO-3, and HOMO-4 form σ + π hybrid orbitals through mixing of Si π-orbitals with the Nb d-orbital. These molecular orbitals illustrate that there are strong interactions between the central Nb and the cage Si atoms. The pd hybridization between the Si and Nb atom interactions strengthens the Si–Nb bonds and, therefore, makes the high-symmetry endohedral \( D_{20} \) structure of NbSi₁₂⁻ more stable. Meanwhile, the occupation of the d-orbital may cause the Nb atom to be negatively charged and stabilize the Nb atom encapsulated within the silicon cage.

The AdNDP method is an efficient tool to decipher the chemical bonding of clusters. As an extension of the MO analysis, AdNDP represents the bonding of a molecule in terms of \( n \)-center two-electron (\( n \text{c} \text{e} \)) bonds, which including the localized (1c–2e lone pairs and 2c–2e bonds) and delocalized (\( n \text{c} \text{e} \) bonds, \( 3 \leq n \leq \text{total number of atoms in the system} \)). Figure 6 depicts the AdNDP bonding pattern for the NbSi₁₂⁻ cluster. The AdNDP analysis reveals 12 localized bonds and 16 delocalized bonds with occupation numbers (ONs) ranging from 1.78 to 2.00 le. The peripheral Si–Si bonds include localized bonding in the form of six 2c–2e σ bonds with an occupation number of ON = 1.95 le and six 2c–2e σ bonds with an occupation number of ON = 1.83 le. For these bonds, each Si atom in NbSi₁₂⁻ can be considered as contributing one σ electron to a 2c–2e σ bond along one Si unit. The delocalized bonding consists of six 3c–2e σ bonds (ON = 1.90 le), six 3c–2e π bonds (ON = 1.78 le), three 9c–2e π bonds (ON = 1.93 le) and one 12c–2e σ bonds with ON = 2.00 le. Each pair of individual Si units can be viewed as contributing one σ electron to form a 3c–2e σ bond with the central Nb atom, while there is also a delocalized 3c–2e π bond between Si₂ units and Nb atom in the NbSi₁₂⁻ cluster. We think that the balance between 3c–2e π and 3c–2e σ bonding pattern in NbSi₁₂⁻ contributes to their large HOMO–LUMO gap (2.70 eV). The 9c–2e bonds describe three completely delocalized π bonds with 6 electrons, and embody the strong bond between the 4d-orbital of Nb and the peripheral Si cage. For the 12c–2e σ bond, the high occupation number of 2.00 le may point to its high electronic stability. The availability of p- and d-orbitals in Nb that can participate in the delocalized bonding with the
peripheral Si atoms leads to substantial stabilization of the $D_{6h}$ symmetry structure of NbSi$_{12}^-$ and makes it the global minimum structure.

4. CONCLUSIONS

In summary, we have performed a global minimum search for the lowest-energy structures of neutral and charged NbSi$_n$$^{Q \pm}$ ($n = 2\rightarrow20; \ Q = 0, \pm 1$) clusters by using the unbiased CALYPSO method combined with density functional theory geometry optimization. Accurate ab initio methods are used to determine relative stabilities and energy ranking among candidates of low-lying isomers. The optimized geometries of the Nb-doped silicon clusters reveal that the metal Nb atom moves gradually from convex capped to surface substituted, to concave, and to encapsulated sites with increasing size of the silicon clusters, and the formation of endohedral structures strongly depends on the size of the cluster. In particular, neutral and anionic NbSi$_{12}$ clusters are found to be regular hexagonal prisms with the Nb atom at the center. The simulated photoelectron spectroscopy is in good agreement with the experimental data across the range of cluster sizes studied. This result further gives us strong confidence to confirm that the lowest energy structures of the NbSi clusters are truly global minimum. We hope that these findings will further stimulate research on transition-metal encapsulated Si-based clusters or other semiconductor clusters.

ASSOCIATED CONTENT

1 Supporting Information
The Supporting Information is available free of charge on the ACS Publications website at DOI: 10.1021/acs.jpcc.6b09453.

Low-lying isomers, vibrational frequencies, and natural electron configuration of neutral and charged niobium-doped silicon clusters NbSi$_n$$^{Q \pm}$ ($n = 2\rightarrow20; \ Q = 0, \pm 1$) (PDF)


